Enhanced Shift Currents in Monolayer 2D GeS and SnS by Strain-Induced Band-Gap Engineering

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SUPPLEMENTARY INFORMATION

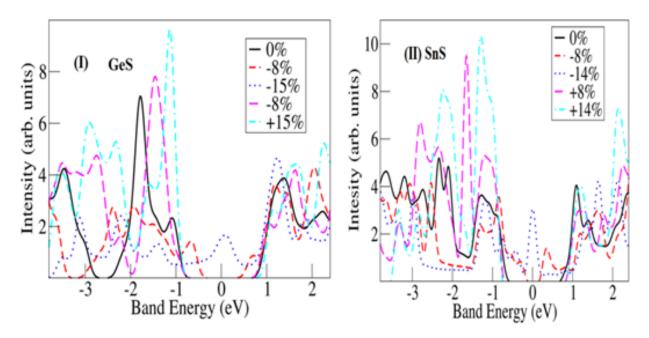


Figure S1: Evolution of the Density of States with Equibiaxial Strain Monolayer 2D GeS and SnS. The figure on the left is for Monolayer 2D GeS and on the right is for SnS.

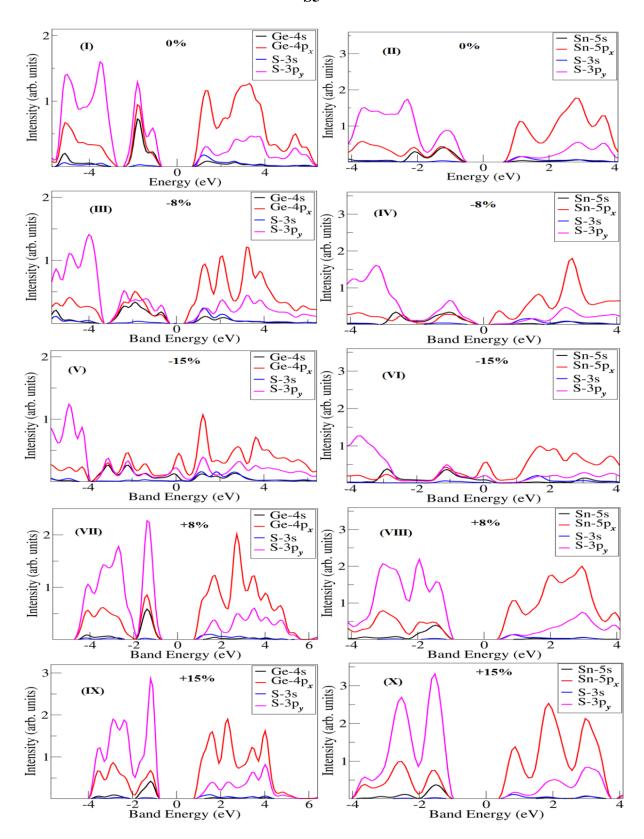


Figure S2: Evolution of the Projected Density of States with Equibiaxial Strain. Monolayer 2D GeS and SnS. The left hand Column is for GeS while the right hand is column for SnS.